



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: JAFARIAN-TEHRANI et al.
Application No.: 10/816,211
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Examiner: UNKNOWN
Group No.: 1763
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Title: METHODS AND ARRAY FOR CREATING A
MATHEMATICAL MODEL OF A PLASMA
PROCESSING SYSTEM

INFORMATION DISCLOSURE STATEMENT

US PATENT DOCUMENTS

Examiner Initials	Cite No.	Document Number	Publication Date	Name of Patentee or Applicant	Reference to Related Case

OTHER DOCUMENTS

Examiner Initials	Cite No.	Description	T
XMS	I	STOUT et al., "Modeling Plasma Tools: Reactor and Feature Scales," pp. 1-6, http://www.google.com/search?q=cache:IPSVCEvzITsJ:cfplasma.trancetechno.com/vmic_2000.pdf+inductively+coupled+plasma	

Examiner Signature	Moser	Date Considered	5-12-08
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